

CORNING

Flexible glass substrates for continuous manufacturing

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Science &
Technology

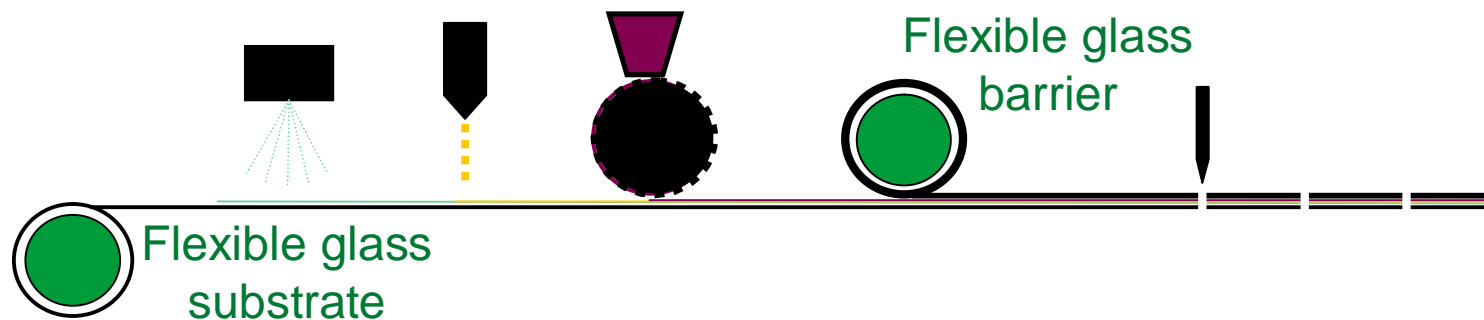
Outline

- Flexible glass for electronic devices
- Flexible glass mechanical reliability
 - Strength
 - Coatings
 - Stress
- Roll-to-roll photolithography
- Summary

Flexible Glass Enables High-Quality Electronics

Substrate choice critical for device fabrication & performance

- Substrate integrates designs, materials, & processes
 - Essential for overall optimization
 - Glass enables improved resolution, registration, performance & lifetime



Flexible Glass

- Thermal stability
- Dimensional stability
- Hermeticity
- Optical transmission
- Surface roughness

Capabilities →

← Requirements

Device Designs

E-paper, touch sensor, PV, OLED

Materials

Conductor, semiconductor, dielectric

Continuous Processes

- Patterning (gravure, ink jet, photolithography)
- Etching (wet, plasma)
- Coating (lamination, slot die, vacuum)

Glass Surface & Bulk Properties Optimize Devices

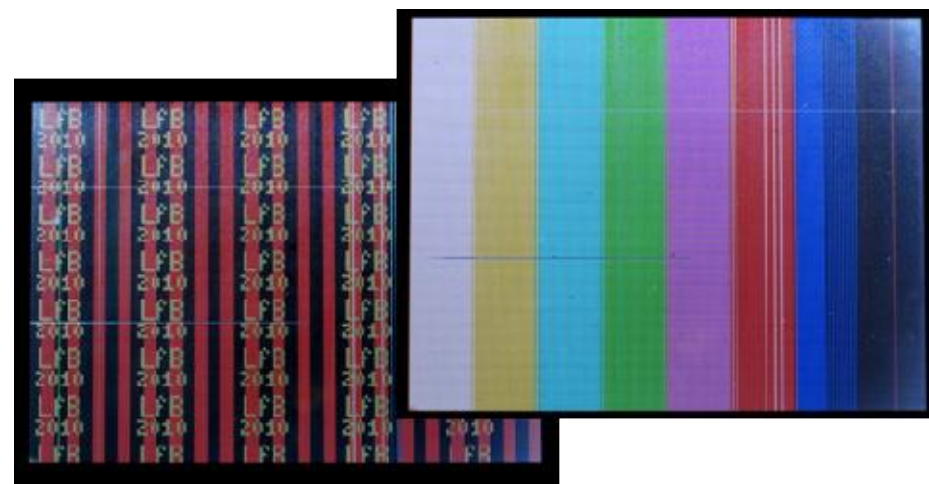
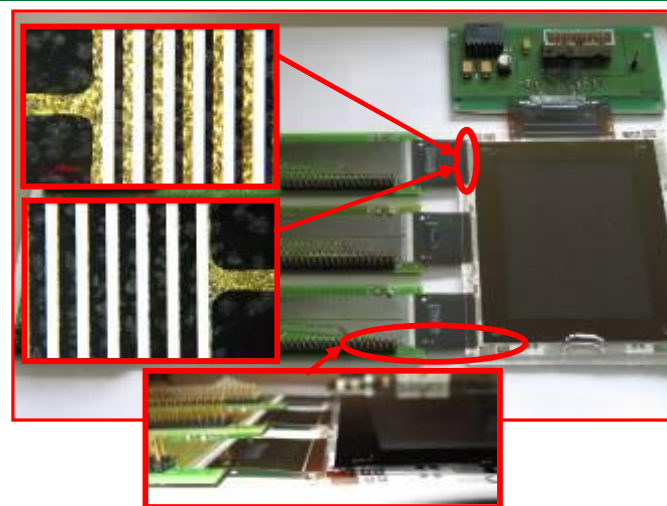
Flexible glass device capability demonstrated in <math><170\mu\text{m}</math> LCD

- Twisted nematic LCD
- qVGA (320 x RGB x 240)
- 4" diagonal (80mm x 60mm)
- Pixel size $83\mu\text{m} \times 250\mu\text{m}$
- Aperture 52%

- a-Si:H active matrix backplane
- TFT channel $L=10\mu\text{m}$, $W=50\mu\text{m}$

- Polymeric substrates not compatible
 - 300°C backplane fabrication
 - 210°C frontplane fabrication

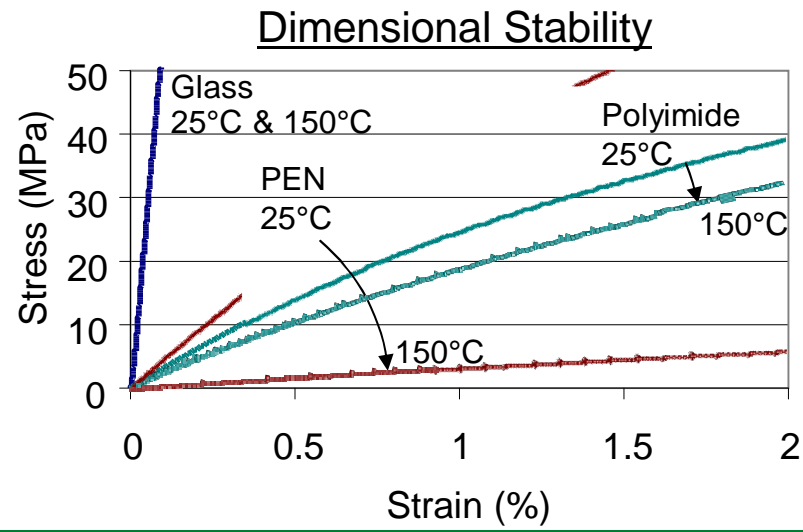
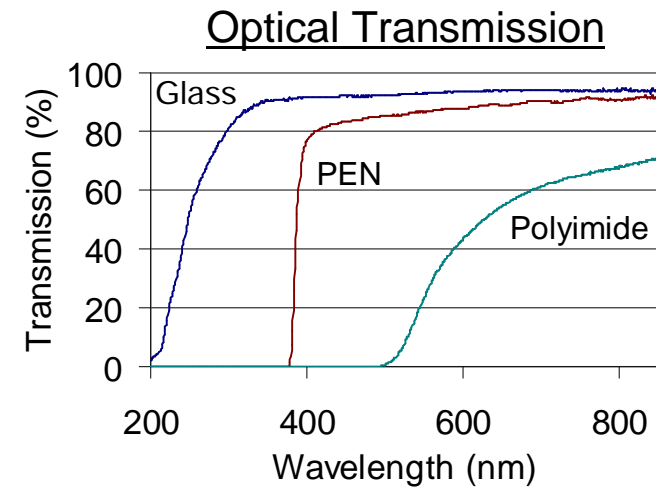
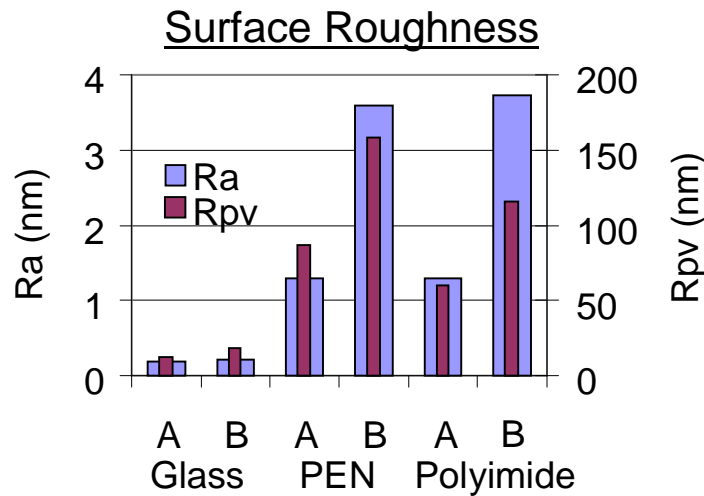
- $75\mu\text{m}$ flexible glass thickness
 - LC cell $<170\mu\text{m}$



S. Hoehla, et al., "Full Color AM-LCDs on Flexible Glass Substrates", IDW 2010, p.1689-1692.

Glass Enables Performance & Process Optimization

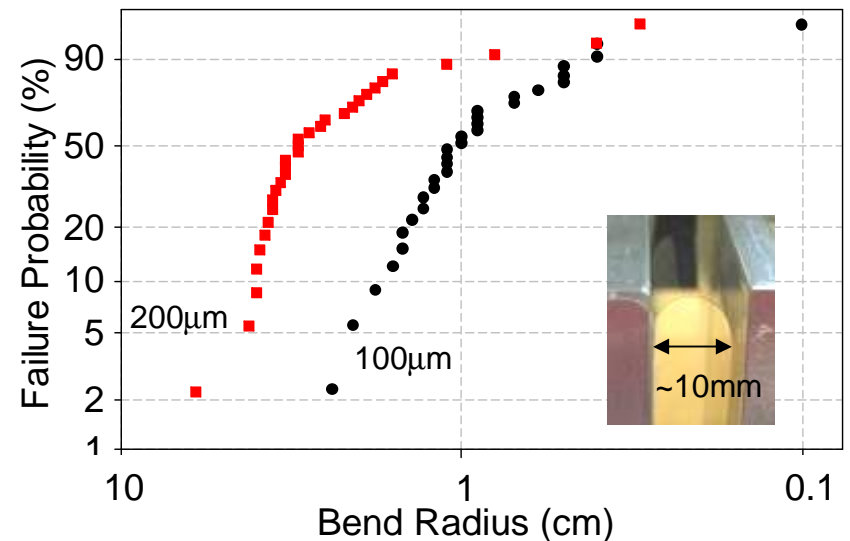
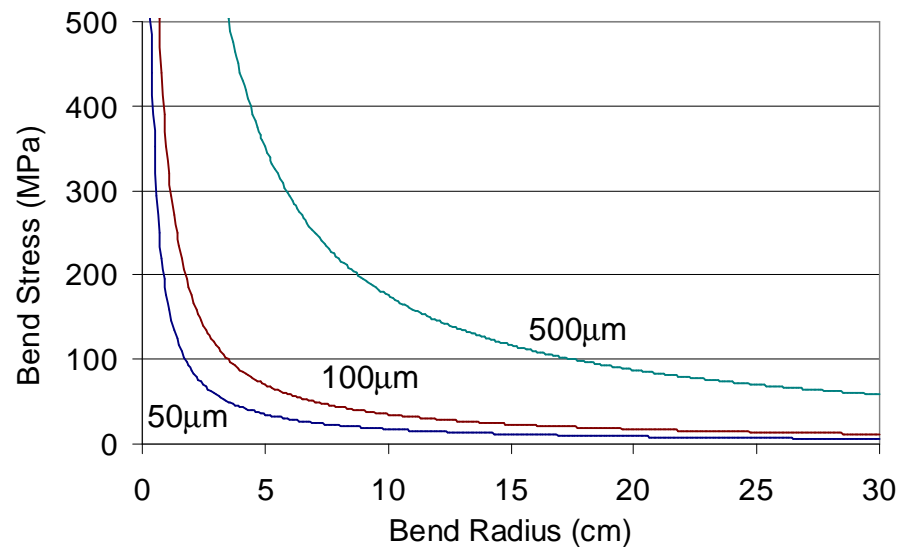
Flexible glass offers dimensional stability for R2R fabrication



Mechanical Reliability of Flexible Glass

Substrate solutions optimized for continuous processing

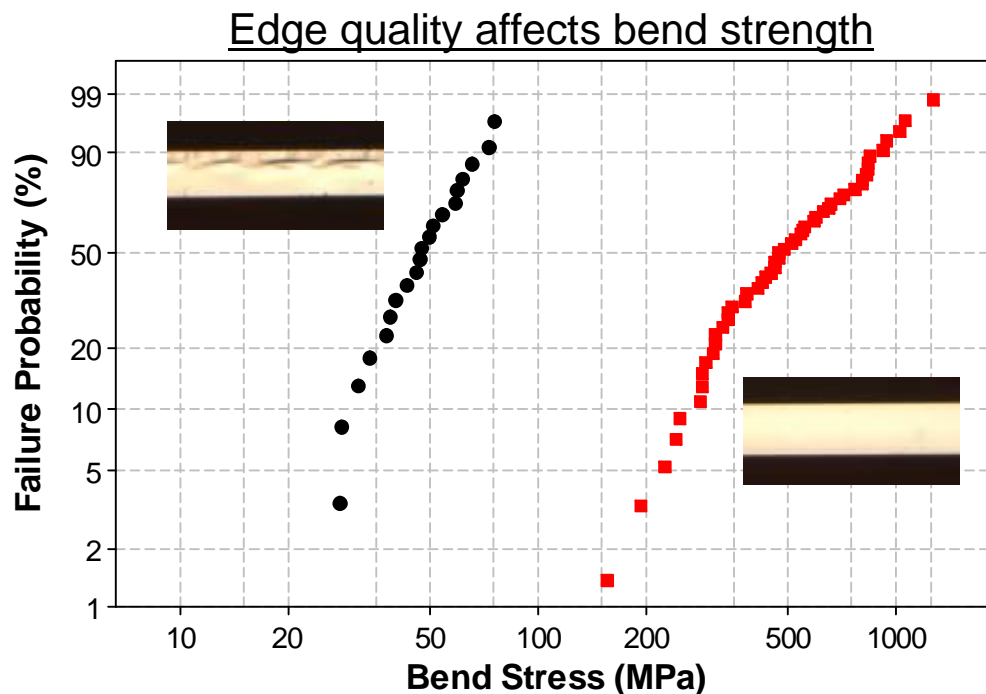
- Mechanical reliability of glass understood
 - Failure due to distributions of defects & applied stresses
 - Bend strength independent of thickness
- Mechanical reliability requires controlling defects & applied stress
 - High strength glass forming including surfaces & edges
 - Protecting substrate from damage
 - Managing stresses during conveyance, handling & application



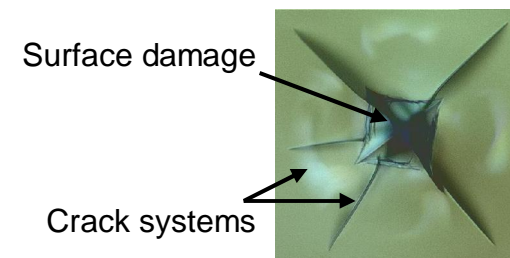
Glass After Forming is Inherently Strong

Managing defect size & distribution enables reliability

- Pristine glass surfaces are extremely strong
 - Bend strengths >6GPa measured in substrate compositions
 - Subsequent handling & environment can reduce strength ~100x
- Glass strength depends on glass history
 - Quality of surfaces & edges critical



Surface quality affects bend strength

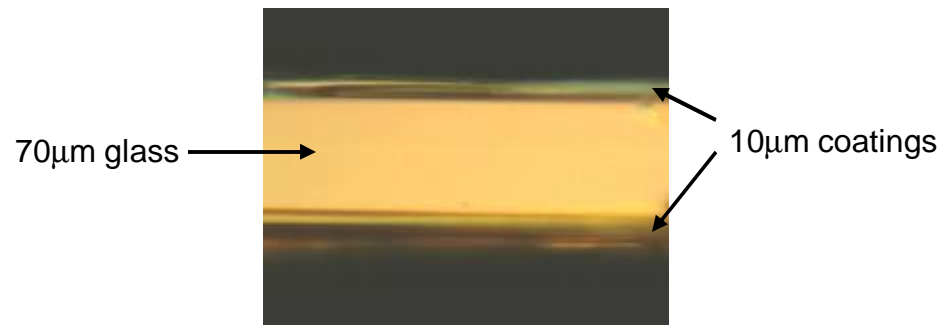


Protective Coatings Preserve Glass Strength

Coating selection specific to application

- Crack systems form when flaw size & stress reach threshold
- Coatings minimize contact damage induced during:
 - Handling, packaging, shipping
 - Device manufacturing
 - In-service use
- Coating optimized for specific device & fabrication processes
 - Material & thickness selected for anticipated conditions
 - Full-width and partial-width coatings enable different device designs
 - Mechanical properties dominated by glass

Coated Substrate Cross-Section

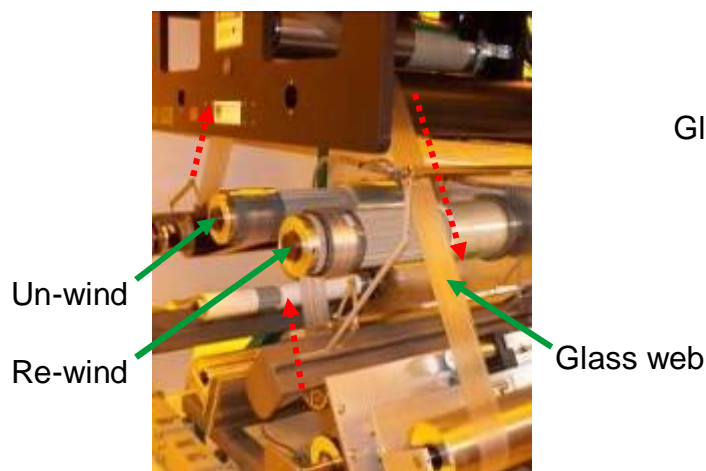


Convey Flexible Glass with Roller Systems

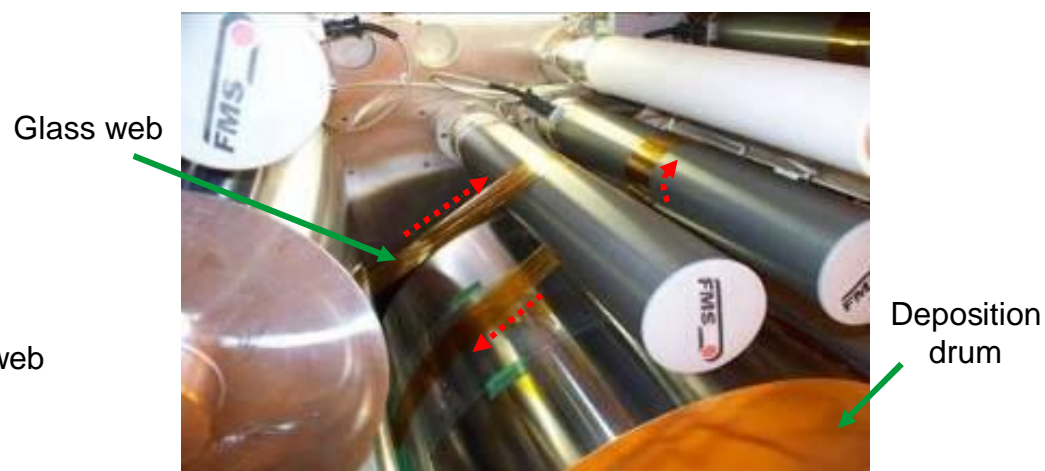
Requires managing bend stress during device fabrication

- Flexible glass is flexible – Do not handle as rigid substrate
 - Stiffness of 50 μm glass \approx 120 μm PEN
 - Control stresses through roller handling system
 - Approach compatible with sheet-fed or roll-to-roll systems

Conveyance in CAMM ECD Tool



Al Sputtering in CAMM General Vac System

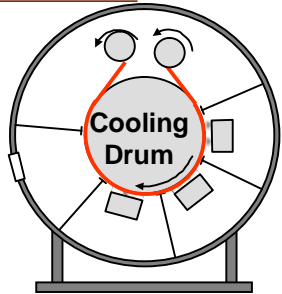


Flexible Glass is Compatible with R2R Processing

Demonstrated continuous ITO patterning

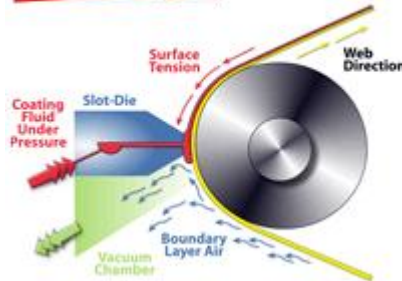
ITO Deposition

CAMM



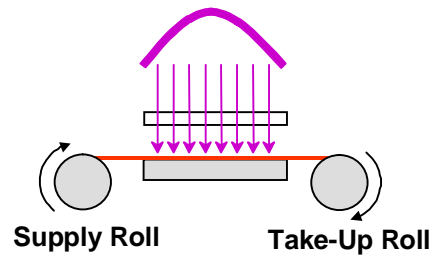
Slot Die Coating

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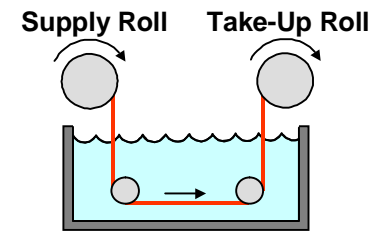
Exposure

CAMM



Development & Etch

CAMM

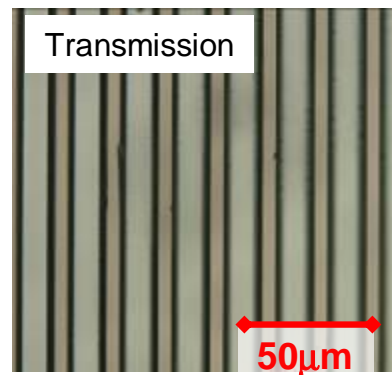
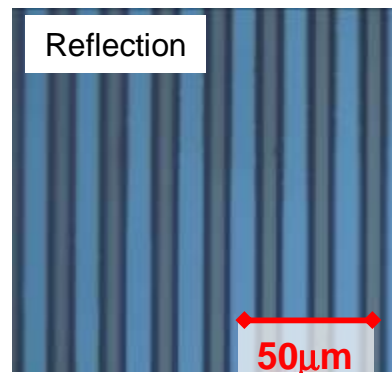


Roll-to-Roll Patterning of 10 μm ITO Lines

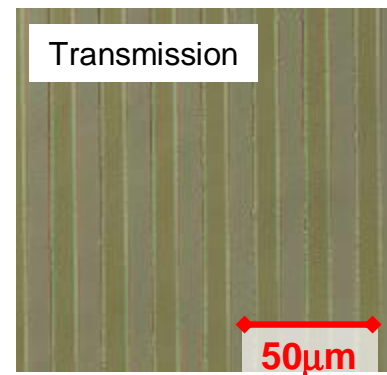
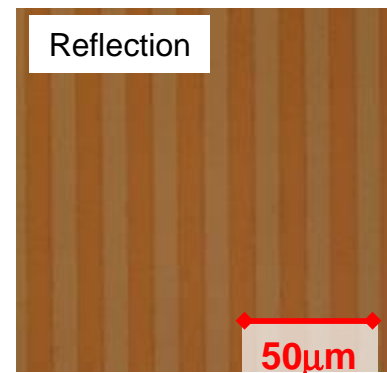
Deposition, slot coat, repeated exposure, develop & etch

- Spooled glass with partial width coating
- 10 μm ITO lines with 30 Ω/\square resistivity

Patterned Photoresist



Patterned ITO



Summary

- Flexible glass offers advantages for device designs, materials & processes
 - Includes dimensional & thermal stability and hermeticity
 - Enables high performance active devices
- Glass mechanical reliability understood
 - Form high initial strength & minimize defects
 - Manage stresses with appropriate conveyance
 - Optimized solutions are application specific
- Flexible glass is compatible with continuous processing
 - Demonstrated patterning of 10 μ m ITO lines
 - Process optimizations possible to take advantage of glass capabilities

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